

Electronic supplementary information

Ternary TiO₂/SiO_x@C nanocomposite derived from a novel titanium-silicon MOF for high-capacity and stable lithium storage

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Experimental

Synthesis of TiO₂/SiO_x@C nanocomposite

The porous TiO₂/SiO_x@C nanocomposite was prepared by a simple two-step process. Firstly, the precursor, namely Ti-Si MOF, was synthesized through solvothermal method¹. 2 g of p-phthalic acid were added into a mixed solution of 36 mL DMF and 4 mL methanol, stirred for 20 min, followed adding titanium tetrabutoxide (TBOT) and tetraethyl orthosilicate (TEOS), according to the mole ratio of TBOT/TEOS=9:1, 8:2, 7:3, 6:4, 5:5, respectively, and the mole ratio of (TBOT+TEOS)/PTA=1:4. After stirring 20 min, the solution was transferred into a Teflon-sealed autoclave and kept at 160 °C for 24 h. The Ti-Si MOF was collected by centrifugation, washed with DMF for 3 times and methanol for 3 times and dried. To obtain TiO₂/SiO_x@C, the Ti-Si MOF was aged at 700 °C for 4 h in N₂ with a speed 5 °C min⁻¹. For comparison, MIL-125 (Ti) and TiO₂@C were prepared according to the abovementioned method just adding 1.04 mL TBOT but not TEOS.

Characterization

The structures of the materials were characterized on a D8 Advance X-ray diffractometer with Cu K α radiation ($\lambda=1.5406$ Å). Field-emission scanning electron microscopy (FESEM) images of the samples was conducted via a

JEOL-7100F scanning electron microscope. Transmission electron microscopy (TEM) images and energy dispersive X-ray spectra (EDX) elemental mappings were collected on a JEM-2100F microscope. The BET surface areas and pore volumes were determined based on a Tristar-3020 instrument at 77 K. Raman spectra and Fourier transform infrared (FT-IR) spectra were recorded by the micro-Raman spectroscopy system (Renishaw INVIA). The carbon contents were obtained from thermogravimetric (TG) (NETZSCH STA 449F5) measurements, during which the samples were heated to 800 °C in air with a heating rate of 10 °C min⁻¹. X-ray photoelectron spectroscopy (XPS) results were collected by a VG MultiLab 2000 instrument.

The electrochemical performance of the synthesized TiO₂/SiO_x@C nanocomposite was evaluated using coin-type cells (CR2016) with lithium metal as the counter electrode. The working electrodes were composed of the active materials, acetylene black and carboxymethylcellulose at a mass ratio of 70:20:10 onto a copper foil. After drying at 70 °C for 12 h, the electrode film was cut into circular discs of about 8 mm in diameter. The coin cells were assembled in an argon-filled glove box. The electrolyte used was composed of 1 M LiPF₆ in a mixture of ethylene carbonate (EC), diethyl-carbonate (DEC), and dimethyl carbonate (DMC) (1:1:1 by volume). Cyclic voltammetry (CV) curves were tested on a CHI 600E electrochemical workstation between 0.01 to 3 V at a scan rate of 0.1 mV s⁻¹. The galvanostatic cycling tests were carried out in the voltage range of 0.01 – 3 V versus Li⁺/Li with LAND CT2001A tester at different current densities. Electrochemical impedance spectroscopy (EIS) tests were performed on Autolab PGSTAT 302N in a frequency range of 0.01–100 kHz.

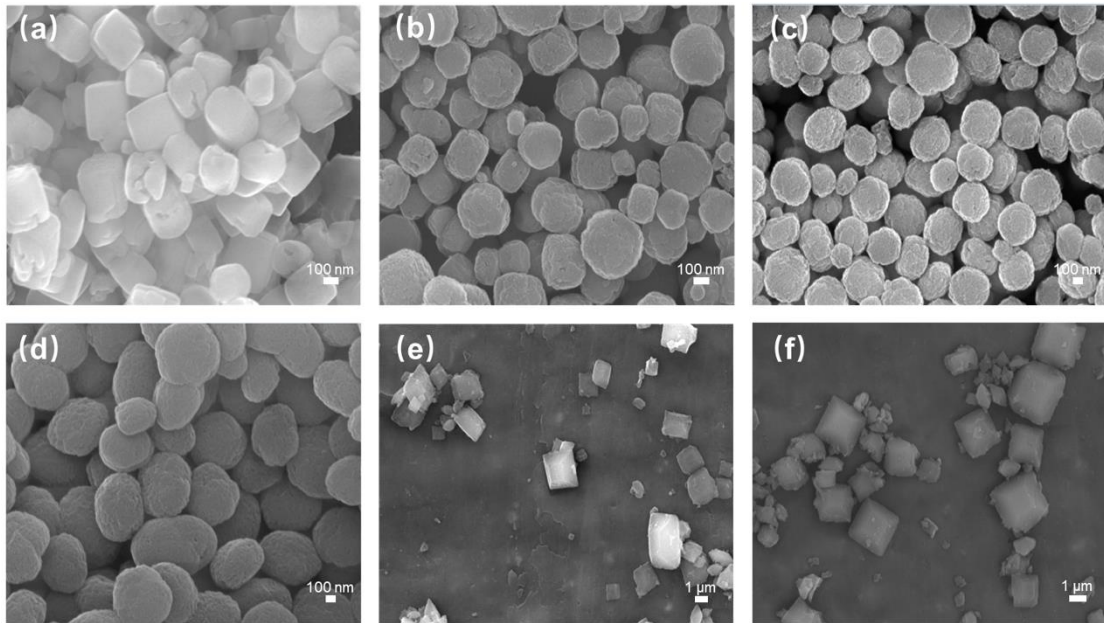


Fig. S1. SEM images of Ti-Si MOF of different feeding proportions of 10:0 (a), 9:1 (b), 8:2 (c), 7:3 (d), 6:4 (e), 5:5 (f).

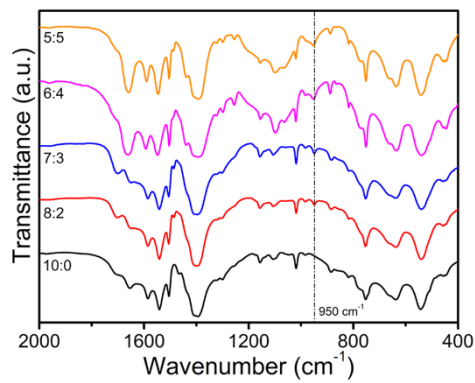


Fig. S2. FT-IR spectra of Ti-Si MOF precursors of different feeding proportions.

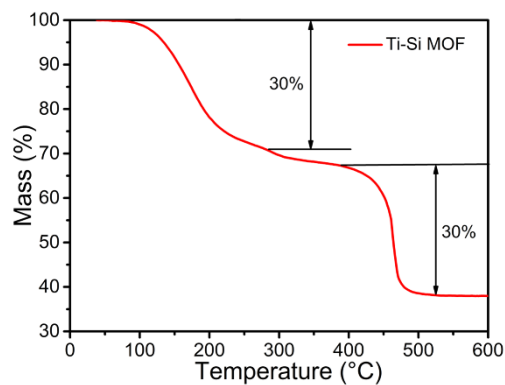


Fig. S3. TGA curve of the Ti-Si MOF precursor.

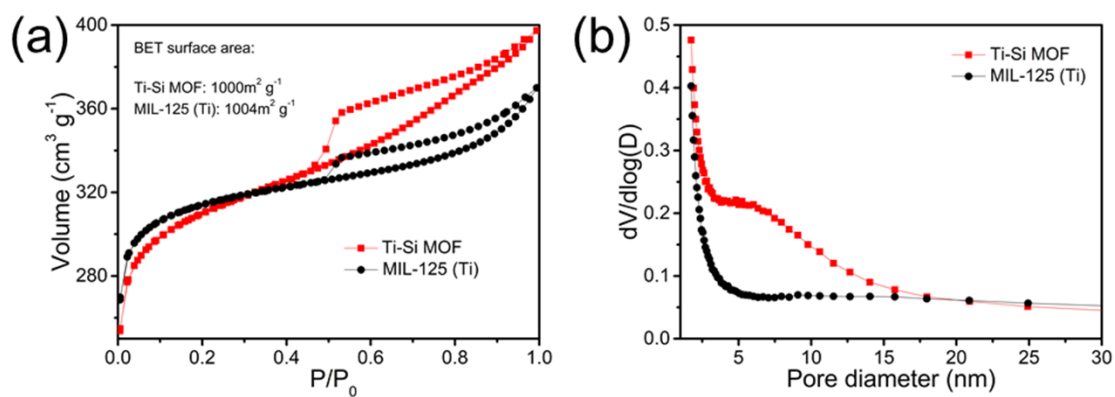


Fig. S4. Different samples of N_2 adsorption desorption isotherm (a) and corresponding pore size distribution (b).

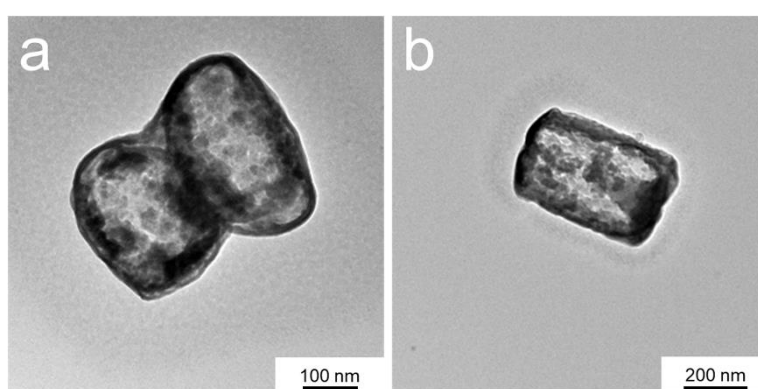


Fig. S5. The carbon matrix obtained by treatment with excess aqueous HF solution.

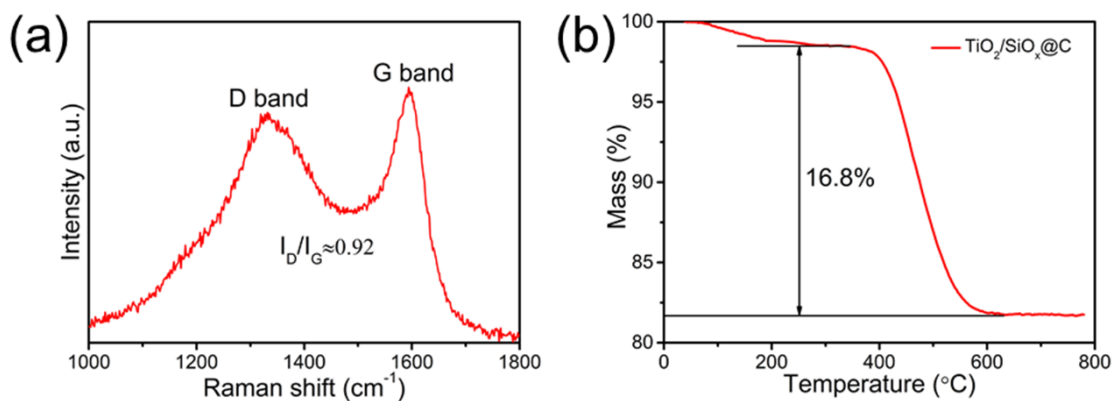


Fig. S6. Characterizations of $TiO_2/SiO_x@C$. (a) Raman spectrum. (b) TGA curve.

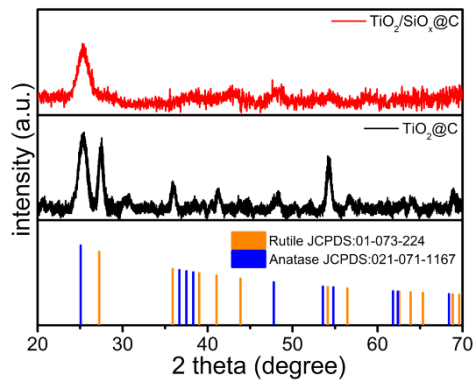


Fig. S7. XRD patterns of $\text{TiO}_2/\text{SiO}_x@\text{C}$ and $\text{TiO}_2@\text{C}$.

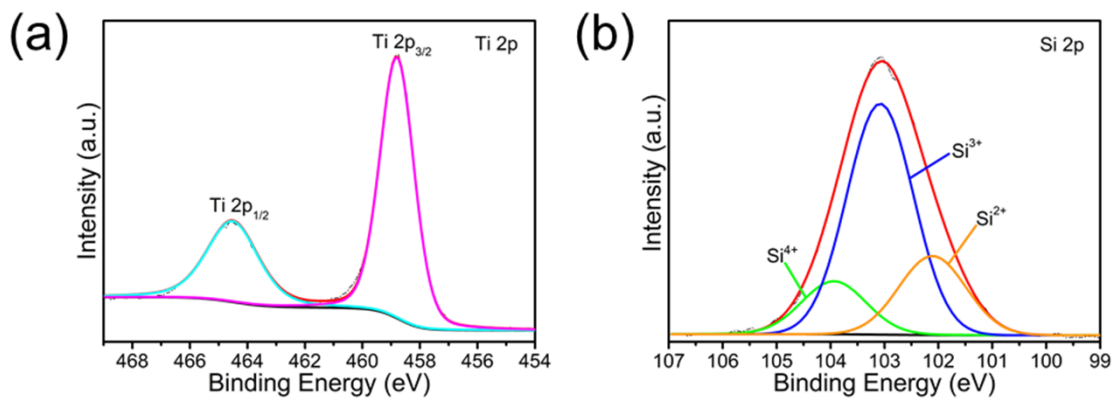


Fig. S8. XPS spectra of $\text{TiO}_2/\text{SiO}_x@\text{C}$. (a) Ti 2p. (b) Si 2p.

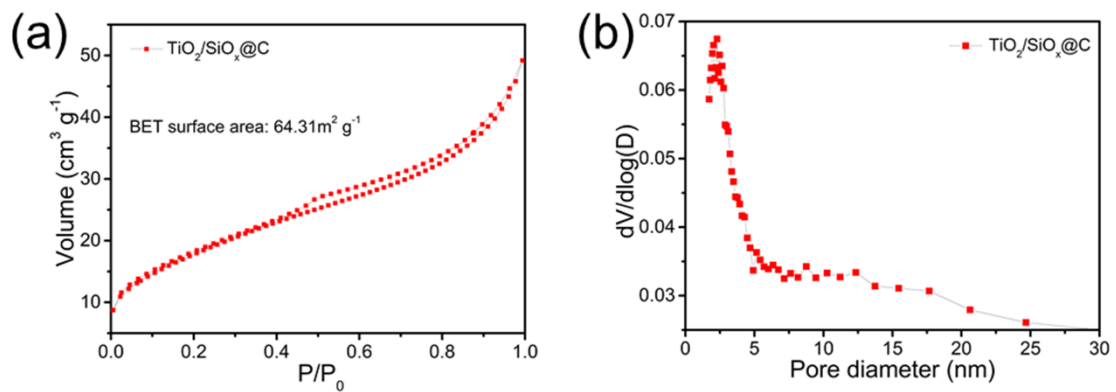


Fig. S9. N_2 adsorption/desorption isotherms $\text{TiO}_2/\text{SiO}_x@\text{C}$ (a) and corresponding pore size distribution (b).

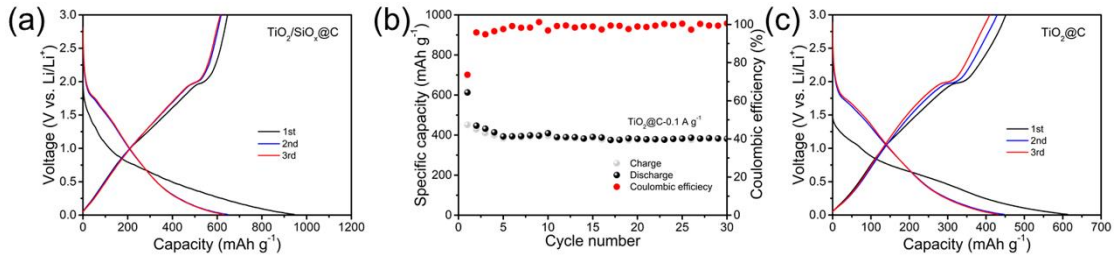
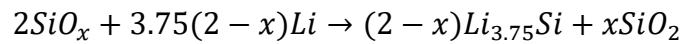


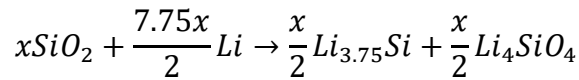
Fig. S10. The electrochemical performances of $\text{TiO}_2/\text{SiO}_x@\text{C}$ and $\text{TiO}_2@\text{C}$ electrodes. (a) The first three charge and discharge profiles of $\text{TiO}_2/\text{SiO}_x@\text{C}$ at 0.1 A g^{-1} . (b) The performance of $\text{TiO}_2@\text{C}$ at 0.1 A g^{-1} and corresponding first three charge and discharge profiles (c) of $\text{TiO}_2@\text{C}$.

The capacity contribution of SiO_x in the $\text{TiO}_2/\text{SiO}_x@\text{C}$ was calculated through analyzing the reaction between SiO_x and Li. First, the reaction between SiO_x and Li follows the equations:²

(1)

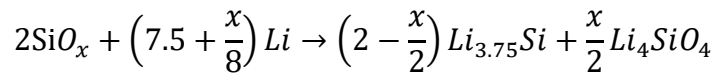


(2)



The reactions of (1) and (2) are combined follow the following equation:

(3)



Therefore, the theoretical first discharge capacity of $\text{SiO}_{1.465}$ is calculated to be $\sim 2000 \text{ mAh g}^{-1}$. From Fig. 10a and Fig. 10c, the first discharge capacities of $\text{TiO}_2/\text{SiO}_x@\text{C}$ and $\text{TiO}_2@\text{C}$ are ~ 945 and $\sim 613 \text{ mAh g}^{-1}$, while the first charge reversible capacities are ~ 647 and $\sim 451 \text{ mAh g}^{-1}$. The Li-insertion ability of TiO_2 and carbon composite component in $\text{TiO}_2/\text{SiO}_x@\text{C}$ is assumed similar to that of $\text{TiO}_2@\text{C}$. Then according to the mass fraction, the capacity of TiO_2 and carbon composite component in $\text{TiO}_2/\text{SiO}_x@\text{C}$ at the first discharge process can be calculated to be $(62.4\% + 16.8\%) \times 613 \text{ mAh g}^{-1} \approx 485 \text{ mAh g}^{-1}$, the capacity of SiO_x component is $(945 - 485) \text{ mAh g}^{-1} = 460 \text{ mAh g}^{-1}$. From the actual delivered capacity and combining its mass fraction, the first discharge capacity of $\text{SiO}_{1.465}$ is calculated to be $(460 \div 20.8\%) \text{ mAh g}^{-1} \approx 2210 \text{ mAh g}^{-1}$. Therefore, the theoretical capacity calculated from the reaction equations is not much different from the first discharge capacity inferred from the actual capacity. Therefore, this assumption and calculation method are reasonable. Further, the reversible capacity of $\text{SiO}_{1.465}$ can be calculated from equation (3) to be $\sim 1240 \text{ mAh g}^{-1}$.

¹. Thus, SiO_x in TiO₂/SiO_x@C provide reversible capacity of (1240 × 20.8%) mAh g⁻¹ ≈ 260 mAh g⁻¹, while the TiO₂ and carbon composite component in TiO₂/SiO_x@C can provide reversible capacity of (647 – 260) mAh g⁻¹ = 387 mAh g⁻¹.

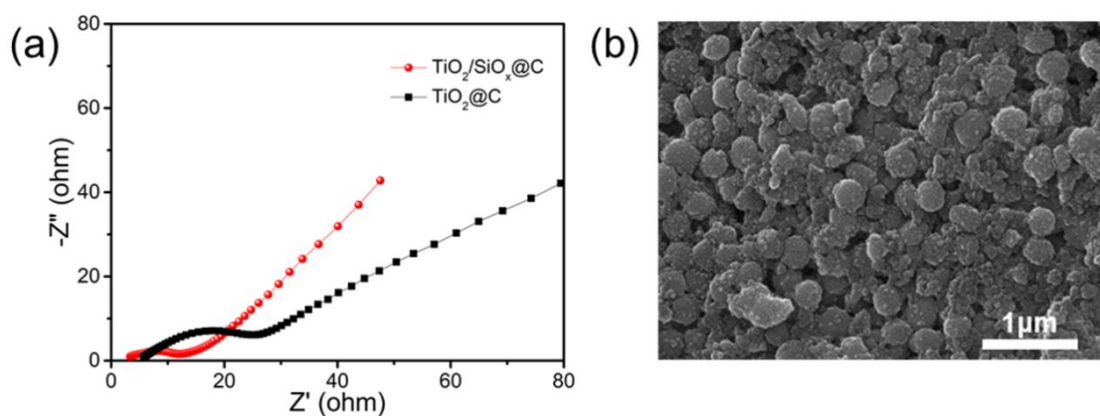


Fig. S11. Characterizations of different electrodes at 1 A g⁻¹ after 100 cycles. (a) EIS profiles of TiO₂/SiO_x@C and TiO₂@C electrodes. (b) SEM image of TiO₂/SiO_x@C electrode.

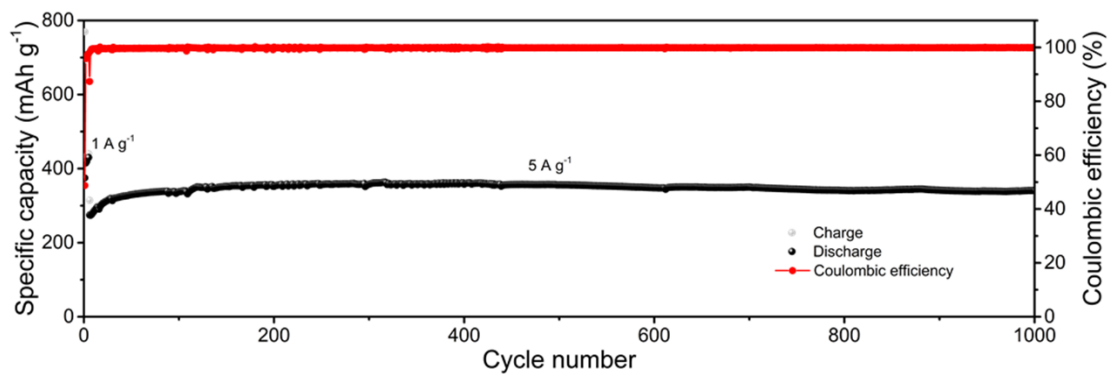


Fig. S12. Long cycle performance of TiO₂/SiO_x@C at the current density of 5 A g⁻¹.

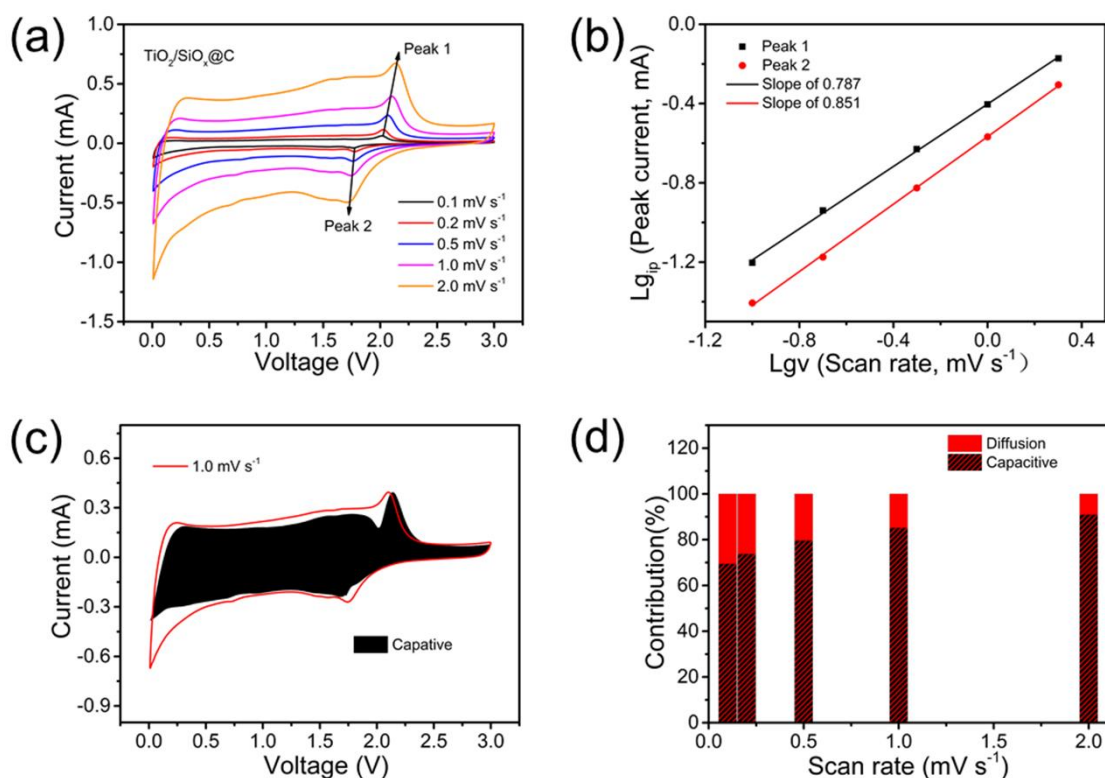


Fig. S13. Characterizations and analyses of electrochemical kinetics of $\text{TiO}_2/\text{SiO}_x@\text{C}$. CV curves (a) of the $\text{TiO}_2/\text{SiO}_x@\text{C}$ at different scan rates and corresponding b values (b) for different peaks. (c) The separation of the capacitive and diffusion currents in $\text{TiO}_2/\text{SiO}_x@\text{C}$ at a scan rate of 1 mV s^{-1} . (d) The percentage of capacitive contribution at different scan rates.

It is generally believed that the peak currents (i_p) and scan rates (v) in the CV tests follow the formula: $i_p = av^b$ (or $\lg i_p = \lg a + b \lg v$), where a is a constant and b is considered to be the slope of the fitting line. When b value approaches 0.5, it represents the diffusion-controlled lithium storage process, while when b value approaches 1.0, it represents the capacitive-controlled process³. CV curves of the $\text{TiO}_2/\text{SiO}_x@\text{C}$ electrode at various scan rates were investigated (Fig. S13a). The b values of $\text{TiO}_2/\text{SiO}_x@\text{C}$ at the chosen two peaks confirm that the pseudo-capacitance contribution (Fig. S13b). The capacitive attribution was assessed to be $\sim 85\%$ at a scan rate of 1 mV s^{-1} as exhibited in shadow region (Fig. S13c). Moreover, the capacitive contribution of $\text{TiO}_2/\text{SiO}_x@\text{C}$ increased with scan rates increasing (Fig. S13d).

Table. S1. Molar ratios of elements in the obtained $\text{TiO}_2/\text{SiO}_x@\text{C}$ material.

Element	Norm. at.%
C	36.89235
O	38.11405
Si	4.666116
Ti	20.32748

Table. S2. Electrochemical performances of various TiO₂-based anodes for LIBs.

Materials	Voltage window	Specific capacity (mAh/ g ⁻¹)/Current density (A g ⁻¹)/Cycle number	Rate capacity (mAh g ⁻¹) Current density (A g ⁻¹)	Ref.
TiO₂/SiO_x@C nanocomposite	0.01-3 V	586/0.1/100	401/5	This work
Rutile TiO ₂ /C	0-3.0 V	400/0.1/100	172/5	4
Anatase TiO ₂ /C	0.01-3 V	~180/0.08/100	123/0.8	5
Anatase TiO ₂ /RGO	1.0-3.0 V	174/0.17/200	88/3.4	6
TiO ₂ (B)/C	0.01-3.0 V	560/0.03/100	200/0.75	7
TiO ₂ -C/MnO ₂	0.01-3 V	352/0.335/100	235/3.35	8
C/SiO _x /TiO ₂	0.01-3 V	400/0.0668/100	200/1.67	9
TiO ₂ /SiO _x /C	0.005 – 3 V	421/0.067/100	---	10
SiO@TiO ₂	0.1 – 3 V	901/0.2/200	272/3	11
TiO ₂ -C-SiO	0.005 – 2 V	674.5/0.14/100	800/1.4	12
TiO ₂ /SiO ₂ -C	0.0 – 3.0 V	502/0.1/300	232/2	13

Reference

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